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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent:	Wenhui Mei	§	Docket No.:	22397.324
Serial No.:	10/064,156	§	Examiner:	Zoila E. Cabrera
Filed:	June 14, 2002	§	Art Unit:	2125
For:	Modified Photolithography Movement System	§	Conf. No.:	5103
		§		

REQUEST FOR PERMISSION TO WITHDRAW AS ATTORNEY OF RECORD

Commissioner for Patents
PO Box 1450
Alexandria, VA 22313-1450

Dear Sir:

I, the attorney signing below, respectfully request permission to withdraw from all further responsibility in this case in accordance with 37 CFR § 10.40(c)(5). I am signing below on behalf of all the other attorneys of record listed in the declaration and power of attorney filed in this case.

I respectfully request that the attorneys of record be granted permission to withdraw from all further responsibility in this case in accordance with 37 CFR § 1.36.

The basis for the request for withdrawal is 37 CFR § 10.40(c)(5), namely, my Client knowingly and freely assents to termination of my employment.

All papers and property concerning this patent have been delivered to the following:

Mr. Hisazumi Ono
Ono & Associates
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JAPAN

Status of subject case: Pending Application

The undersigned respectfully requests approval. **This form submitted in TRIPLICATE.**

Respectfully submitted,

David M. O'Dell
Reg. No. 42,044

Date: 3-6-06

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